



Sheet 1 of 1 (10/7/04)

Form PTO-1449		ATTY. DOCKET NO. 0475-0193P		APPLICATION NO. 09/890,804				
INFORMATION DISCLOSURE CITATION IN AN APPLICATION (Use several sheets if necessary)				APPLICANT Holger HAUPTMANN et al.				
				FILING DATE October 1, 2001		GROUP 1731		
U.S. PATENT DOCUMENTS								
EXAMINER INITIAL	DOCUMENT NUMBER	Kind	DATE	NAME	CLASS	SUB CLASS	FILING DATE IF APPROPRIATE	
<i>[Handwritten initials]</i>	US 6,106,747	A	2000-08-22	Wohlwend				
	US							
	US							
	US							
FOREIGN PATENT DOCUMENTS								
Office	DOCUMENT NUMBER	Kind	DATE	COUNTRY	CLASS	SUB CLASS	TRANSLATION	
							YES	NO
<i>[Handwritten initials]</i>	DE	121 025	1975-08-19	GERMANY <i>R?</i>				
	EP	0 583 620	A1	1994-02-23	EUROPE			
OTHER DOCUMENTS (Include Name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.) date, page(s), volume-issue number(s), publisher, city and/or country where published.								
<i>[Handwritten initials]</i>	S. J. ROCK et al., "Distortion Control for P/M-Based Rapid Prototyping of Advanced Material Components", presented at 1996 World Congress on Powder Metallurgy & Particulate Materials, June 16-21, 1996, Washington, D.C. pp. 1-15							
<i>[Handwritten initials]</i>	H. E. AMAYA, "Size & Distortion Control in MIM Processing", Advances in Powder Metallurgy, Vol. 2, pp. 285-295, June 9, 1991							
	Renfert, Katalog 97/98, p. 60 <i>Date? Release</i>							
<i>[Handwritten initials]</i>	"Modern Practice in Dental Ceramics", W.B. Saunders Company, Philadelphia and London, 1967, pp. 280-285, 290, 291							
	VMK 95, VITA Zahnfabrik H. Rauter GmbH & Co., KG, printed 07/8/98 drawings <i>Date?</i>							
	Keramik heute, VITA Zahnfabrik H. Rauter GmbH & Co., KG, printed 12/86, pp. 8, 9 <i>Date Release</i>							
EXAMINER <i>[Handwritten signature]</i> DATE CONSIDERED <i>11-28/15-04</i>								
EXAMINER: Initial if citation considered, whether or not citation is in conformance with M.P.E.P. 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.								

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